EXHIBITION & MARKETING



Marketing Package (Closing Date August 10, 2020)

Marketing Package "LANE"

Regular: € 1,500 incl. 19 % VAT

Presenting author: € 1,200 incl. 19 % VAT

- Conference participation for one person
- Company profile on LANE website
- Your logo appears on the conference website, in the final program, on the sponsor posters and in the LANE App
- One full-page advert (color) in the final program

Exhibition Packages

(Closing Date August 10, 2020)

Exhibition Package "Micro"

Regular: € 1,900 incl. 19 % VAT

Presenting author: € 1,500 incl. 19 % VAT

- Marketing Package "LANE" (including conference participation for one person)
- Appearance at the exhibition during LANE
- > Booth with an exhibition space of 3 m x 2 m
- > 1 table, 2 chairs
- > Power supply (~ 230 V, 16 A)
- > Booth surveillance during talks

Exhibition Package "Macro"

Regular: € 2,500 incl. 19 % VAT

Presenting author: € 2,000 incl. 19 % VAT

- Marketing Package "LANE" (including conference participation for one person)
- Conference participation for one additional person
- Appearance at the exhibition during LANE
- > Booth with an exhibition space of max. 16 m²
- > 2 tables, 4 chairs
- > Power supply (~ 230 V, 16 A)
- > Booth surveillance during talks

Registration on www.lane-conference.org

ORGANISATIONAL ISSUES







Venue

Stadthalle Fürth

Rosenstraße 50, 90762 Fürth, Germany www.stadthalle-fuerth.de

Conference Fees

Presenting author

Regular participant

Complete conference: € 890 incl. 7 % VAT3-day participation: € 770 incl. 7 % VAT2-day participation: € 650 incl. 7 % VAT1-day participation: € 530 incl. 7 % VATDeadline for registration: August 10, 2020

Members of CIRP / WGP / WLT / ELI / JLPS / Swissphotonics / bayern photonics e.V. / Optence e.V. are granted a general discount of 10 % on these fees. Payments should be made on receipt of invoice. For payment with credit cards from outside the EU, a service fee of 7 % will be charged. Costs for bank transfer are for the account of the registrant. The conference fees include admission to the presentations, the exhibition, the social events, lunch, refreshments and coffee breaks.

The regular participant (not presenting author) may cancel the event up to 14 days prior to its commencement in return for 50 % of the participation fee. Thereafter, or should the participant fail to appear, we will charge the full participation fee. The fee for presenting authors is not refundable because the fee covers the publication costs. Bayerisches Laserzentrum GmbH will accept an alternate participant / speaker without additional charges. Cancellations, revocations or changes in bookings must be in written form.

Please note our General Terms and Conditions for participation at events held by Bayerisches Laserzentrum GmbH on the conference website www.lane-conference.org.

The organisers provide assurance that LANE 2020 will be conducted in accordance with IUPAP principles as stated in the IUPAP resolution passed by the General Assembly in 2008 and 2011. In particular, no bona fide scientist will be excluded from participation on the grounds of national origin, nationality, or political considerations unrelated to science.





Conference Organisation

Bayerisches Laserzentrum GmbH Institute of Photonic Technologies Friedrich-Alexander-Universität Erlangen-Nürnberg

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Photos: K. Cvecek, K. Fuchs, P. Götz, K. Hofmann, M. Holzer, T. Langer (langermachtfotos.de), Stadthalle Fürth - E. Malter





Fürth | Germany

until January 24, 2020









SCOPE & TOPICS







<u>ш</u>ЯПТЕО:

TOPICS FOR

SPECIAL SESSIONS

If you are interested in a

relevant topic concerning photonic

technologies, that is not stated here,

please let us know until November 30,

2019. Together with the Knights of Laser

Technology we will discuss, whether

we will consider this topic as a

special session for

LANE 2020.

Scientific Impact & Industrial Relevance

LANE 2020 offers a platform for the international exchange of ideas, results and solutions concerning the application and the perspectives of photonic technologies. Especially recent developments in the field of

Laser Material Processing

- > Beam sources & components
- > Laser beam welding, brazing & soldering
- > Laser beam cutting & drilling
- > Surface treatment & forming
- > Laser assisted processes

including

- > Experimental results
- > Simulation & modeling
- > Sensing & control
- > Laser safety

are of interest. In order to open up the capabilities of light, it is essential to look ahead. Against this background LANE 2020 wants to enhance the

Emerging Technologies

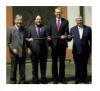
- > Additive Manufacturing
- > Precision processing with ultrashort laser pulses
- > Fast laser beam manipulation
- > Laser material processing in the visible wavelength range
- > E-Mobility/Batteries

Progress needs the integration of the scientific and also the industrial point of view. Therefore, we call for scientific contributions that will be reviewed and – if accepted – published online on Elsevier's Procedia CIRP. Furthermore, we are looking for industrial contributions that will be evaluated on their relevance for application and – if accepted – published on the LANE website.

ROUND TABLE OF KNIGHTS & PRELIMINARY PROGRAM







Round Table of Knights

The Knights of Laser Technology, together with the editors and the local organiszation committee form the scientific scope of LANE and take care of the relevance of the topics and contributions. LANE takes place under their patronage.

Prof. Craig B. Arnold, USA

Prof. Manfred Geiger, Germany

Prof. Werner Jüptner, Germany

Prof. Jean-Pierre Kruth, Belgium

Prof. Johan Meijer, The Netherlands Prof. Isamu Mivamoto. Japan

Prof. Dieter Schuöcker, Austria

Prof. Hans Kurt Tönshoff, Germany

Prof. Frank Vollertsen, Germany



Preliminary Conference Program

For the first time four days of LANE conference will offer the possibility to listen to and discuss even more interesting talks.

Sunday, September 06, 2020: Casual reception

> Eve-registration & smooth start

Monday, September 07, 2020: 1st conference day

- > Opening remarks
- > WLT Award ceremony
- > Plenary session with keynote presentations
- > Parallel sessions & exhibition
- > Night of the Knights: Conference banquet

Tuesday, September 08, 2020: 2nd conference day

> Parallel sessions and exhibition

Wednesday, September 09, 2020: 3rd conference day

- > Parallel sessions & exhibition
- > Cocktail session & lab-tour

Thursday, September 10, 2020: 4th conference day

- > Parallel sessions & exhibition
- > Closing plenary session
- > LANE Best Presentation Award
- > Closing remarks

SUBMISSION & PUBLICATION



Reviewed and accepted scientific papers will be published online on Elsevier's *Procedia CIRP*

Proceedings

Accepted scientific contributions will be published in Elsevier's open access journal *Procedia CIRP*. By allowing conference delegates to publish their reviewed papers in a dedicated issue on ScienceDirect, which is freely and in perpetuity available throughout the world, it facilitates a fast dissemination. The proceedings are indexed in Scopus, the largest abstract and citation database of peer-reviewed literature.

Organisation

Bayerisches Laserzentrum GmbH (blz) in cooperation with the Institute of Photonic Technologies (LPT), Friedrich-Alexander-Universität Erlangen-Nürnberg

Submission of short abstracts

Timeline for 2020 until January 24

 About 150 words written in English
Upload as plain text to ConfTool https://www.conftool.org/lane-conference-2020

February 05 Notification of acceptance

until March 15 Submission of scientific and industrial papers

Double-blind paper review by the review committee

May 11 Notification of review results

Revisions have to be done to the accepted papers according to the reviewers'

comments, if required

until June 01 Submission of final revised papers

Please note: Accepted contributions have to be presented personally at the conference

until June 25 Registration deadline for presenting authors

September 06 LANE conference starts

Online publication of accepted papers:

Scientific papers will be published in Elsevier's Procedia CIRP, industrial papers on LANE website

International Review Committee



Quality assurance

These independent experts are responsible for the reviews of the contributions and assure the quality of the papers:

C. B. Arnold, Princeton University, USA · P. Aubry, CEA/Université Paris-Saclay, France · S. Barcikowski, University of Duisburg-Essen, Germany · P. Bartolo, The University of Manchester, United Kingdom J. P. Bergmann, Technische Universität Ilmenau, Germany · D. Bourell, The University of Texas at Austin, USA · M. Brandt, RMIT University, Australia · B. Chichkov, Laser Zentrum Hannover e.V., Germany A. Clare. The University of Nottingham, United Kingdom · G. Dearden, University of Liverpool, United Kingdom · P. Delaporte, Aix-Marseille Université, France I. Drstvenšek, University of Maribor, Slovenia · D. Drummer, Friedrich-Alexander-Universität Erlangen-Nürnberg, Germany · J. Duflou, KU Leuven, Belgium C. Emmelmann, Hamburg University of Technology, Germany · R. Fabbro, Arts et Métiers ParisTech, France · A. Fougères, Institut National d'Optique, Canada · T. Frick, Technische Hochschule Nürnberg Georg Simon Ohm, Germany · P. Galarneau, Institut National d'Optique, Canada · E. Govekar, University of Liubliana, Slovenia T. Graf, University of Stuttgart, Germany · C. Grigoropoulos, University of California at Berkeley, USA · D. P. Hand, Heriot-Watt University, United Kingdom · G. Hennig. Daetwyler Graphics AG, Switzerland · P. Hoffmann, ERLAS Erlanger Lasertechnik GmbH, Germany · R. Holtz, University of Applied Sciences and Arts Northwestern Switzerland, Switzerland · H. Huber, Munich University of Applied Sciences, Germany Y. Ito, Nagaoka University of Technology, Japan · A. Jesacher, Medical University of Innsbruck, Austria · W. Jüptner, Universität Bremen, Germany · S. Kaierle, Laser Zentrum Hannover e.V., Germany · A. Kaplan, Luleå University of Technology. Sweden · S. Katayama, Osaka University, Japan · M. Kogel-Hollacher, Precitec GmbH & Co. KG, Germany · D. Kracht, Laser Zentrum Hannover e.V., Germany P. Krakhmalev, Karlstad University, Sweden · J.-P. Kruth, KU Leuven, Belgium · V. Kunjanpää, Lappeenranta University of Technology LUT, Finland · J. K. Larsson Autokropolis Engineering, Sweden · B. Lauwers, KU Leuven, Belgium · L. Li. The University of Manchester, United Kingdom · K. Löffler, TRUMPF Lasertechnik GmbH. Germany J. Meijer, University of Twente, The Netherlands C. Merklein. Schaeffler Technologies AG & Co. KG, Germany · M. Merklein, Friedrich-Alexander-Universität Erlangen-Nürnberg, Germany · I. Miyamoto, Osaka University, Japan C. L. Molpeceres Alvarez, Technical University of Madrid, Spain · S.-J. Na, Xi'an Jiaotong University, China B. Neuenschwander, Bern University of Applied Sciences, Switzerland · F. Oefele, BMW AG, Germany · S. Olschok, RWTH Aachen University, Germany · A. Ostendorf, Ruhr-Universität Bochum, Germany · A. Otto, Vienna University of Technology, Austria · L. Overmeyer, Laser Zentrum Hannover e.V., Germany · F. Palm, Airbus Defence and Space GmbH, Germany · M. Pereira. Universidade Federal de Santa Catarina, Brazil · D. Petring, Fraunhofer Institute for Laser Technology ILT, Germany · F. E. Pfefferkorn, University of Wisconsin-Madison, USA · P. Plapper, University of Luxembourg, Luxembourg · J. M. Pou, University of Vigo, Spain · R. Ramsayer, Robert Bosch GmbH, Germany · U. Reisgen, RWTH Aachen University, Germany · M. Rethmeier, Bundesanstalt für Materialforschung und -prüfung, Germany · G.-W. Römer, University of Twente, The Netherlands A. Salminen, Lappeenranta University of Technology LUT, Finland P. Salter, University of Oxford, United Kingdom · D. Schmid, AUDI AG, Germany · M. Schmidt, Friedrich-Alexander-Universität Erlangen-Nürnberg, Germany · R. Schmitt, Fraunhofer Institute for Production Technology IPT, Germany · I. Smurov, École Nationale d'Ingénieurs de Saint-Etienne, France · K. Sugioka, RIKEN Center for Advanced Photonics, Japan · H.-K. Tönshoff, Leibniz Universität Hannover, Germany E. Tovserkani, University of Waterloo, Canada J. Tremel, Robert Bosch GmbH. Germany · G. Turichin, Peter the Great St.Petersburg Polytechnic University, Russia F. Vollertsen, BIAS GmbH, Germany · K. Wegener, ETH Zurich, Switzerland P. Weidinger, Brose Fahrzeugteile GmbH & Co. KG, Germany · M. F. Zäh, Technische Universität München, Germany · Z. Zalevsky, Bar-llan University, Israel M. Zhong, Tsinghua University, China · D. Zibar, Technical University of Denmark,